

References:

1. A good introduction to ESR is provided by J.H. Weil, J.R. Bolton, and J.E. Wertz, *Electron Paramagnetic Resonance: Elementary Theory and Practical Applications* (Wiley, New York, 1994).
2. Application of ESR to a particularly important system in solid state electronics, the MOS system is reviewed by P.M. Lenahan and J.F. Conley, Jr., *J. Vac. Sci. Technol.*, **B16**, 2134 (1998).
3. D.J. Lepine, *Phys. Rev. B* **6**, 426 (1972).
4. D. Kaplan, I. Solomon, and N. F. Mott, *J. Phys. Lett.* **39**, 51 (1978).
5. C.J. Cochrane, P.M. Lenahan, A.J. Lelis, *Appl. Phys. Lett.* **100**, 023509 (2012); 7
6. C.J. Cochrane, P.M. Lenahan, A.J. Lelis, *J. Appl. Phys.* **109**, 014506 (2011).
7. B.C. Bittel, P.M. Lenahan, J.T. Ryan, J. Fronheiser, A.J. Lelis, *Appl. Phys. Lett.* **99**, 083504 (2011).
8. J.W. Gabrys, P.M. Lenahan, W. Weber, *Microelectronic Eng.* **22**, 273 (1993).
9. P.M. Lenahan, W.K. Schubert, *Phys. Rev. B.* **30**, 1544 (1984).
10. T.D. Mishima, P.M. Lenahan, *IEEE Trans. NS* **47**, 2249 (2000).
11. J.T. Ryan, P.M. Lenahan, A.T. Krishnan, et al., *J. Appl. Phys.* **108**, 064511 (2010).
12. C.J. Cochrane, P.M. Lenahan, A.J. Lelis, *J. Appl. Phys.* **105**, 064502 (2009).
13. J.P. Campbell, P.M. Lenahan, A.T. Krishnan, et al., *J. Appl. Phys.* **103**, 044505 (2008).
14. P.M. Lenahan, P.V. Dressendorfer, *J. Appl. Phys.* **55**, 3495 (1984).
15. D.T. Krick, P.M. Lenahan, *J. Appl. Phys.* **64**, 3558 (1988).
16. Y. Nishi, A. Ohwada, K. Tanaka, *Jap. J. Appl. Phys.* **11**, 85 (1972).
17. P.J. Caplan, E.H. Poindexter, B.E. Deal, et al., *J. Appl. Phys.* **50**, 5847 (1979).
18. G.D. Watkins, *J. Crystal Growth* **159**, 338 (1996).
19. B.K. Meyer, W. Stadler, *J. Crystal Growth* **161**, 119 (1996).
20. P. Emanuelsson, P. Omling, B.K. Meyer, et al., *Phys. Rev. B.* **47**, 23 (1993).
21. B.K. Meyer, P. Omling, E. Weigel, et al., *Phys. Rev. B.* **46**, 23 (1992).
22. D.M. Hofmann, P. Omling, H.G. Grimmeiss, et al., *Phys. Rev. B.* **45**, 11 (1992).
23. I. Stefaniuk, M. Bester, I.S. Virt, M. Kuzma, *Acta Physica Polonica A* **108**, 2 (2005).
24. D. Verstraeten, C. Longeaud, et al., *Semicond. Sci. Technol.* **18**, 11 (2003).
25. P. Christmann, B.K. Meyer, et al., *Phys. Rev. B.* **53**, 7 (1996).
26. K. Saminadayar, D. Galland, E. Molya, *Solid State Communications* **49**, 627 (1984).
27. H.J. von Bardeleben, J.C. Launay, V. Mazoyer, *Appl. Phys. Lett.* **63**, 8 (1993).
28. D. Christmann, D. Volm, B. K. Meyer, et al., *Semicond. Sci. Technol.* **10**, 290 (1995).
29. K. Saminadayar, J.M. Francou, J.L. Pautrat, *J. Crystal Growth* **72**, 236 (1985).
30. C.J. Cochrane, P.M. Lenahan, A.J. Lelis, *J. Appl. Phys.* **105**, 064502, (2009).

These references correspond to references found on the previous 3 pdf links on the website